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**(54) Title (EN):** BEAM-SPECIFIC POWER CONTROL

**(54) Title (FR):** CONTRÔLE DE PUISSANCE SPÉCIFIQUE D'UN FAISCEAU

**(57) Abstract:**

**(EN):** Embodiments of the present disclosure describe methods and apparatuses for beam-specific power control.

**(FR):** Des modes de réalisation de la présente invention décrivent des procédés et des appareils de contrôle de puissance spécifique d'un faisceau.

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**Declarations:**

Declaration as to non-prejudicial disclosures or exceptions to lack of novelty (Rules 4.17(v) and 51bis.1(a)(v))